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Optimization Design of Self-Triggered Complex Detector for Space Range-Gated Imaging System

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ABSTRACT To further enhance transient characteristics of space range-gated imaging system and widen its application potential in astronomical and military domains, a self-triggered structure and complex detecting mechanism are proposed in this paper. There being delays restriction among multiple subsystem of range-gated imaging system and the robust performance of multiple optical axis adjusted are firstly discussed and analyzed. Based on these, by researching the work principle and coupling process of microchannel plates in series in image intensifier, taking advantages of the coupling loss electrons to realize self-triggered is studied and its prototype device structure is further proposed too. Then, the space optical transfer theory of new self-triggered component is deduced and its waveguide process is simulated in the software. Finally, the self-trigger performance and optical transfer effect of cutting edge invention is verified by vacuum test. And the test results basically match with theoretical model and simulation data.

INDEX TERMS Micro channel plate (MCP), range-gated imaging, self-triggered, complex detector.

I. INTRODUCTION

In recent years, as an advanced imaging technology with distinguished signal-to-noise ratio (SNR) and transient detecting ability, active range-gated imaging has been widely studied and applied in space awareness and military field [1]–[5]. Thanks to the rapid progress of laser and optics technology and imaging detector, some performances of range-gated imaging have made great improvements, especially the time resolution of some subsystems or components have reached the nanosecond level [6]–[9]. However, in practical applications, many delays between each subsystems or components have created a critical barrier to further enhancements of time resolution to transient imaging [10]–[12]. Namely, it is extremely difficult for multiple subsystems to realize a synchronization trigger at the nanosecond level in the range-gated imaging process, which directly limits further progress of the overall system [13]–[16]. Therefore, it is very worthwhile to reduce or cancel the series delays in range-gated imaging system [17]–[19].

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On the other hand, in order to receive more echo optical power from space, larger and larger aperture of optical antenna never fails to fascinate designer of space optoelectronic system. But, excessive aperture will directly cause longer focal length for ensuring quality of imaging. As key triggered component, avalanche photodiode (APD) is field stop of traditional range-gated imaging system. Meanwhile, in order to ensure transient trigger of range-gated imaging, the photo surface of APD is not too large, generally is sub-millimeter scale. Therefore, the field of view (FOV) is usually greatly limited by the excessive aperture and minute FOV. In the micro-assembly process of range-gated imaging system, there is a precise adjusting step between echo trigger and laser emitting optical axis. Visibly, the precise adjusting of multiple optical axis can not only greatly limit its FOV and flexibility of space range-gated imaging, but also obviously enhance the risk of off-axis and reduce the reliability of range-gated imaging system in the space.

To address above both issues, a complex detecting device mechanism is proposed in this paper. We took advantages of coupling loss electrons between the MCPs to self-triggered transient imaging, which will directly avoid the series delays

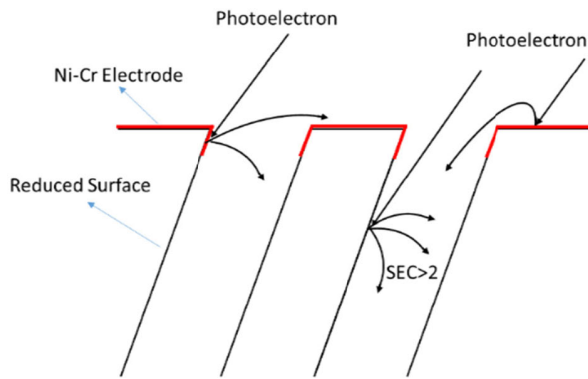


FIGURE 1. Coupling loss electron schematic diagram.

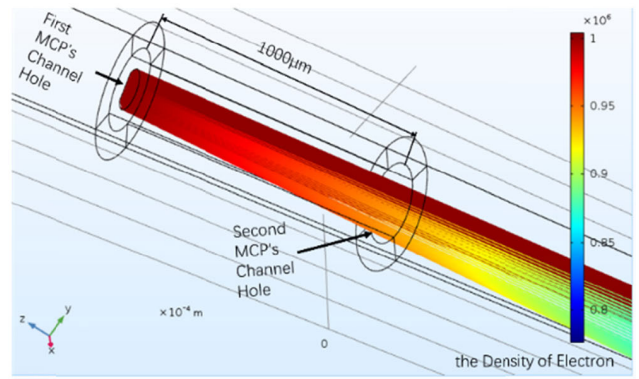
from every subsystem and immediately enhance transient characteristics of range-gated imaging system, but also make the echo trigger and range-gated imaging subsystem combine two into one, and effectively improve robustness of range-gated imaging system in tough environments.

II. SELF-TRIGGERED MECHANISM

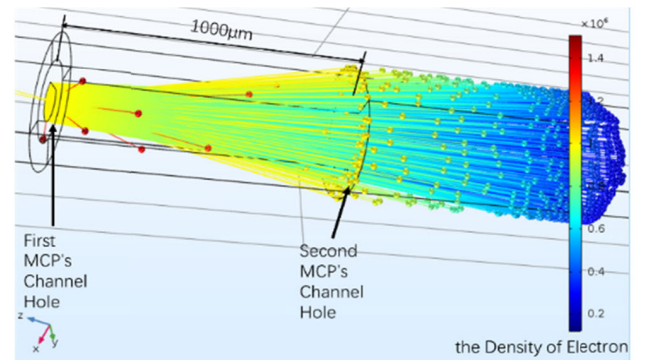
As the core component of range-gated imaging system, image intensifier provides the vast majority of amplification and gain of transient imaging [20], [21]. Therein, microchannel plate (MCP) is a distinguished electric-vacuum amplification device whose gain can reach 10^5 and frequency response is close to sub-nanosecond. Usually, two microchannel plates in series were widely applied by image intensifier for enhancing the gain of transient imaging. However, upon the work principle of MCP, there being two Ni-Cr thin film electrodes on the both sides of MCP is indispensable for supplement and multiplication of the currents [22]–[25]. The device structure will immediately lead to electrons loss of coupling between MCPs and obviously reduce the currents density received by the second MCP. As shown in Fig. 1.

Many of electron beams are collected by the Ni-Cr electrode at the input of the MCP. Theoretically, the coupling efficiency can be dominated by designing parameter of the waveguide structure MCPs such as electric field distribution and gap scale between MCPs [26]–[28]. For example, in the Fig.2, the proportion of coupling loss can be obviously altered by only selecting both extreme bias voltages in the same waveguide structure. Herewith, by precisely controlling parameters of the whole waveguide structure can directly affect the proportion of the coupling loss from 20% to 90%.

On the basis, this paper proposed that setting a micro array-holes waveguide gate between both MCPs to collect coupling loss for self-trigger or other complex detecting [29]–[31]. As shown in Fig. 3, compared with MCP, the micro array-holes waveguide gate can be regarded as a microchannel plate with lower aperture ratio, there being metal conductive layer attached in the inner wall of the holes and no multiplication. The array-holes can be manufactured by laser-engraved on a mica plate of 20 microns. And MCP₂ and the array hole



(a) There being 1000V between the lower surface and the upper surface of the MCPs



(b) There being 0V between the lower surface and the upper surface of the MCPs

FIGURE 2. Electron beam diffusion in coupling Process.

can be installed together by physical proximity model. The concrete structure and working principle of the prototype device are shown in Fig.4. The X of CsPbX₃ in the Fig.3 can adopt Br. Generally the bandgap of CsPbBr₃ is around 2.26eV and its emitting wavelength concentrate upon Green color. Because a random lasing based on CsPbBr₃ pumped by high energy electric beam has been verified in our team other paper. So taking advantages of CsPbBr₃ can contribute to reduce noise from electric amplification. Its manufacturing method and process are as follows. The quantum dot spin coating solution obtained by one-step spin coating method is dropped on a conductive glass substrate through a special syringe. Finally, spin coating resulted in a uniformly translucent CsPbBr₃ quantum dot film. Besides, the conductivity of the perovskite layer can be set around 7 s/m.

When the echo laser pulse is focused on the photocathode by the optical antenna, a number of photo electrons with space imaging information are triggered from the photocathode. Under external electronic field, the photoelectrons stimulated by the laser pulse will enter into the MCP₁ to complete itself multiplication and to shape electron beam including space imaging information. Subsequently, the EB will be divided into two by the micro array-holes waveguide gate. Therein, the majority of EB is collected by the metal conductive

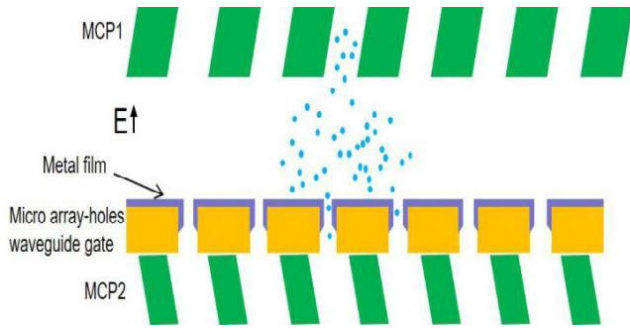


FIGURE 3. Micro array-hole waveguide gate mechanism.

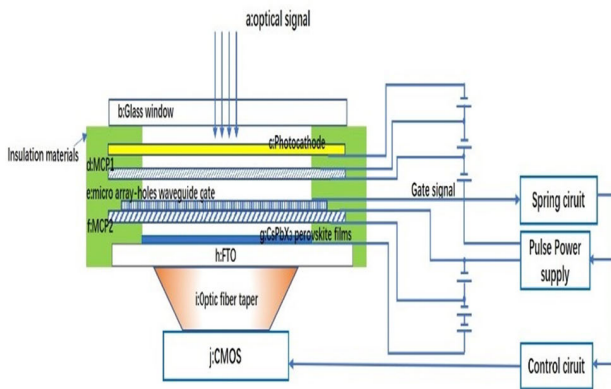


FIGURE 4. The prototype device structure and principle.

layer of micro array-holes waveguide gate during waveguide process, and the others of EB will pass through the micro array-holes waveguide gate and enter into the second MCP to recover the power of EB. The part collected by the metal conductive layer of EB is used for instantaneously triggered imaging and pulse power supply of MCP₂. The remaining part of EB amplified by the MCP₂ will transfer initial space imaging information to the final luminescent screen. Because of there being effect of self-saturated gain in multiple MCPs in series, collected EB's power from the coupling between MCPs will little affect the weak signal detection ability of overall device.

III. MODEL ANALYSIS AND SIMULATION

As shown in Fig. 4, theoretically, the overall resolution (S) of the image intensifier is mainly affected by the gap between photocathode and MCP₁, the distance between anode and MCP₂, and concrete structure parameters of micro array-holes waveguide gate, which is approximately expressed as:

$$\frac{1}{S^2} = \frac{1}{S_{in}^2} + \frac{2}{S_{mcp}^2} + \frac{1}{S_{gate}^2} + \frac{1}{S_{out}^2} \quad (1)$$

It is known that the molecule size of photocathode and anode are so minute sufficiently that the constraint of both portions can be neglected to overall resolution. Besides, thanks to great enhancement of MCP manufacturing technology, the hole scale of MCP has reached micron order. Upon

the sampling theorem of MCP, its resolution can be expressed as:

$$S_{mcp} = \frac{1000}{\sqrt{3p}} \quad (2)$$

where the p represents the diameter of MCP's hole. Visibly, if the p is around several microns, the overall resolution (S) is little affected by the dimensions of MCP. However, in traditional image intensifier, the distance between MCP₂ and anode is mainly restricted factor. Because of there being external high voltage accelerates EB for the anode emitting light, the distance between MCP₂ and anode generally cannot too tiny, which will directly diffuse EB focal spot and lose space imaging information. Note that in traditional image intensifier, multiple MCPs generally take advantages of proximity focusing to install for reducing EB diffusion. But in order to add micro array-holes waveguide gate between MCPs, the gap taken by the micro array-holes waveguide gate will become a new avoidable bottleneck.

Resolution expression of the both parts can be approximately as the process of EB diffusion in vacuum. So their resolution expression can be written as:

$$S_{out} = 2D_{out} \sqrt{\frac{2E_x}{qU_{out}}} \quad (3)$$

$$S_{gate} = 2D_{gate} \sqrt{\frac{2E_x}{qU_{gate}}} \quad (4)$$

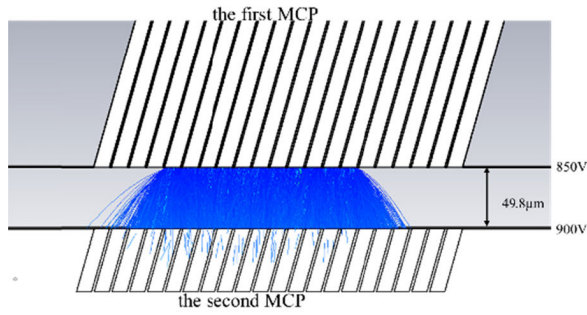
where the E_x represents the initial average kinetic energy of electron from MCP, and the D_{gate} and U_{gate} are respectively the gap and voltage between MCP₁ and micro array-holes waveguide gate, and the D_{out} and U_{out} are respectively the distance and the voltage between MCP₂ and anode. However, in the above formula, although the D_{gate} and D_{out} linearly affect relative resolution, and the U_{out} around several thousand voltages is generally far more than U_{gate} around several dozen voltages. Therefore, the S_{gate} is mainly and newly limited factor, and the structure parameters of micro array-holes waveguide gate should be optimized as much as possible.

Upon the optical imaging and estimate theory, space optical transfer characteristics of imaging system can be measured by normalizing the real part of the Fourier transform of point impulse function. Generally, modulation transfer function (MTF) represented by the real part of point impulse function can effectively show attenuation process space of frequency spectrum between object and image. On the basis. The optical transfer expression of the new image intensifier system can be simplified as follows.

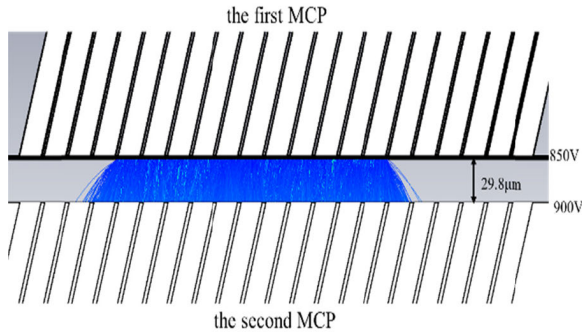
$$MTF = MTF_{in} \times 2MTF_{mcp} \times MTF_{gate} \times MTF_{out} \quad (5)$$

The MTF of MCP can be given by equation 6, where p is the diameter of every micro hole and f is the space frequency of imaging and J₁ represents the first order Bessel function.

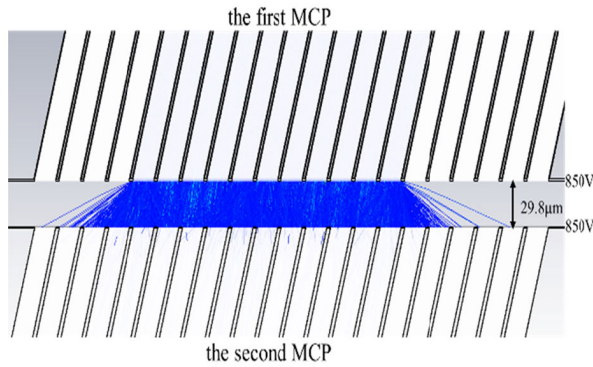
$$MTF_{mcp} = \left| \frac{J_1(2\pi f p)}{\pi f p} \right| \quad (6)$$



(a) Under the same voltage the excessive waveguide gap leads to uneven distribution of electric field



(b) Under the same voltage the distance between two MCPs is around 30 μm leads to reasonable electric field distribution



(c) Under the different voltage leads to lack of guide electric field

FIGURE 5. Difference of coupling loss.

The MTF of proximity cathode can be expressed as:

$$MTF_{in} = \exp\left(-4\pi^2 D_{in}^2 f^2 \frac{E_{in}}{U_{in}}\right) \quad (7)$$

where D_{in} is proximity gap between cathode and MCP_1 , and E_{in} is initial kinetic energy of electrons from cathode into vacuum, and the U_{in} is the voltage between MCP_1 and cathode.

Similarly, the MTF of anode and micro array-holes waveguide gate can be expressed as:

$$MTF_{anode} = \exp\left(-\frac{\pi^2 D_{anode}^2 f^2 E_x}{9U_{out}^2}\right) \quad (8)$$

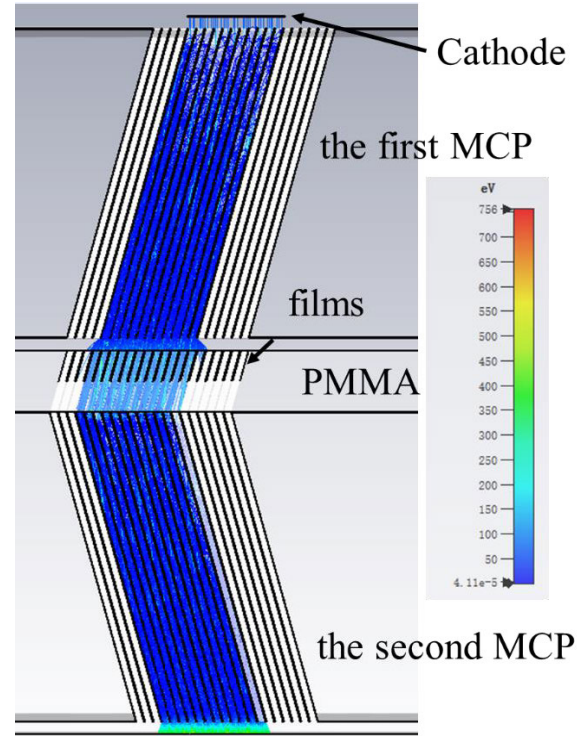


FIGURE 6. Integrated waveguide process.

$$MTF_{gate} = \exp\left(-\frac{\pi^2 D_{gate}^2 f^2 E_x}{9U_{gate}^2}\right) \quad (9)$$

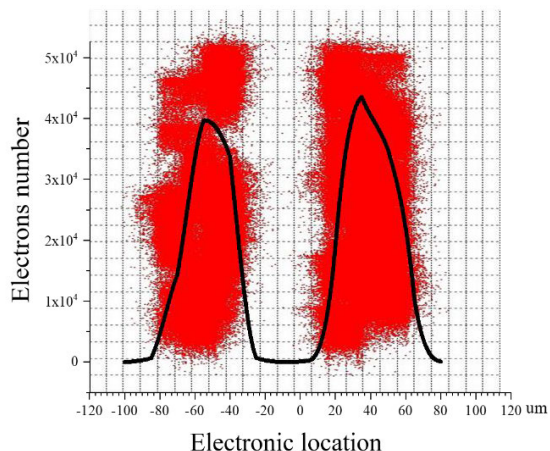
By comparing with other sub MTF function expression, the MTF_{gate} plays the most important role in the overall MTF of the new-type image intensifier. Especially, the precise manufacturing and optimized designing of D_{gate} and U_{gate} are importance of final imaging. Visibly, provided the structure parameters of micro array-holes waveguide gate set reasonably, the initial EB imaging information is little affected by the diffusion of waveguide structure. And Fig.6 shows the overall waveguide process of Fig.5 .

In the system of Fig.6, we set several typical resolution patterns which are respectively 10lp/mm, 12.5lp/mm, 15lp/mm and 20lp/mm as imaging targets. After waveguide transfer, their corresponding patterns at image space can be showed in Fig. 7.

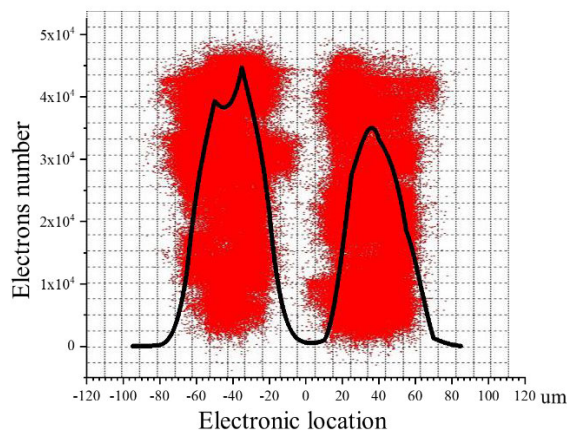
To sum up, upon theoretical analysis of from 6 to 9 formula, we fitted the theoretical optical transfer function of micro array-holes waveguide gate depending on simulating data, as shown in Fig.8. It is not difficult to find that the above several typical simulated patterns almost match with the theoretical optical transfer function. The space optical transfer ability of new device structure can satisfy practical application and additional self-triggered component basically does not affect imaging performance of overall image intensifier.

IV. MANUFACTURING AND TESTING

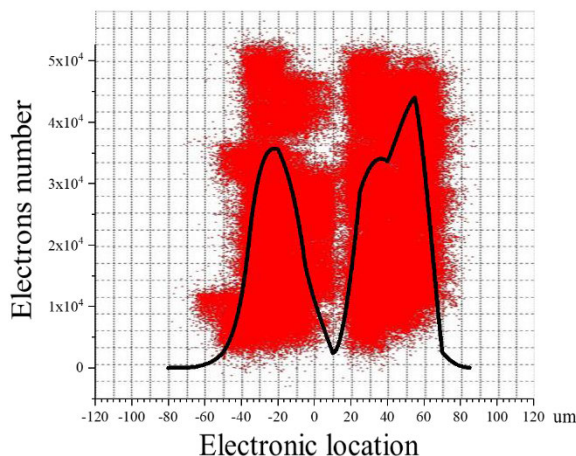
In order to further verify the above theoretical analysis and simulation results, we established a prototype device in the



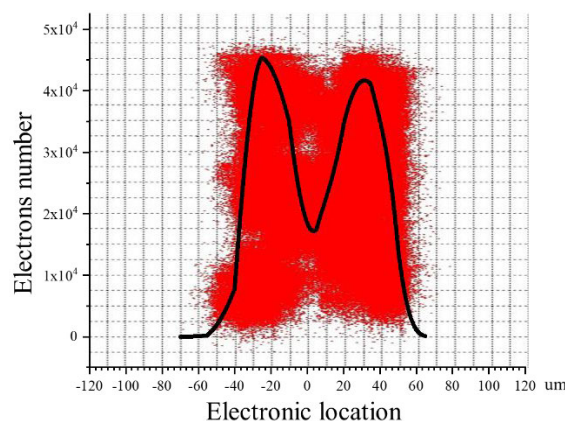
(a)10lp/mm Electric pattern at image space



(b)12.5lp/mm Electric pattern at image space



(c)15lp/mm Electric pattern at image space



(d)20lp/mm Electric pattern at image space

FIGURE 7. Electric-optical space transfer effect.

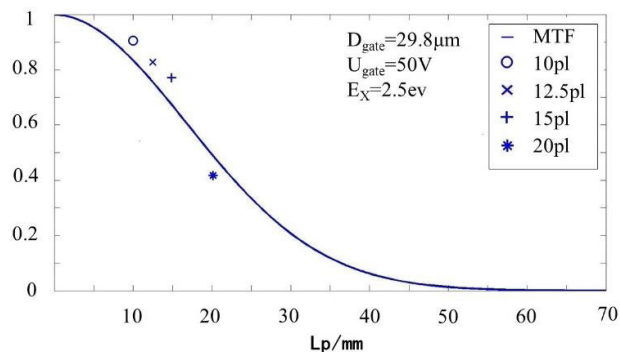


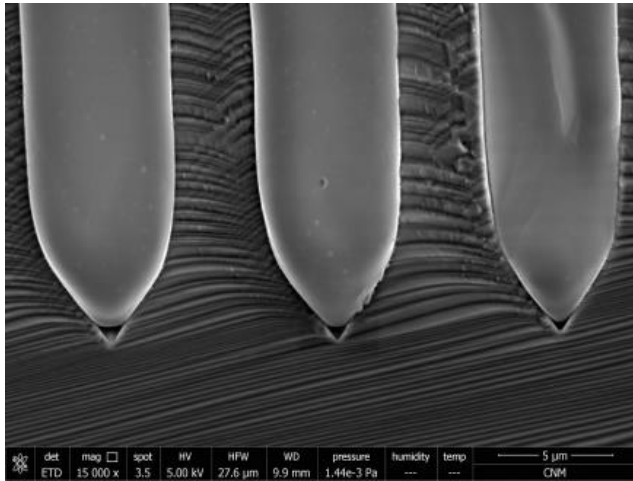
FIGURE 8. Optical transfer function.

vacuum in light of the Fig.4. The concrete manufacturing process and steps are as follows.

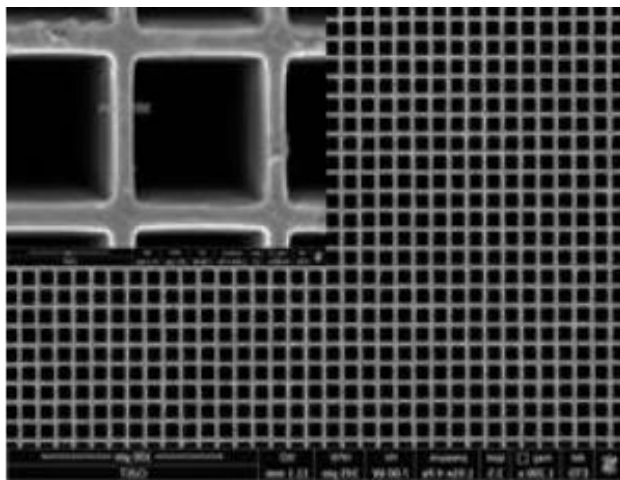
The first step, we took advantages of silicon slice as the substrate to manufacture micro array-holes waveguide gate. A massive of induced pits were etched in the sili-

con slice by inductively coupled plasma (ICP). The process and result of detailed manufacturing can be shown in Fig.9.

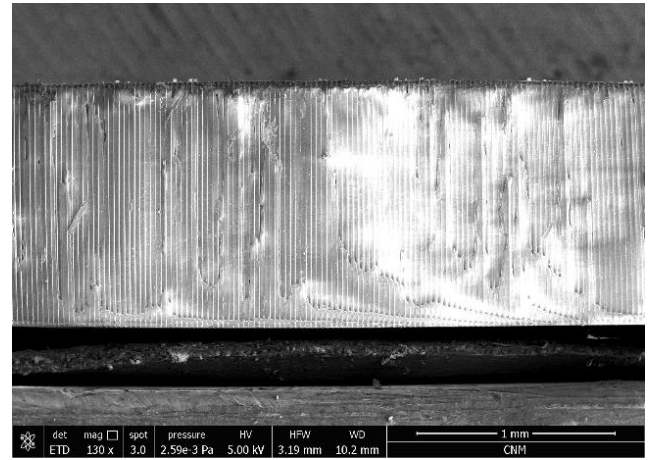
The second step, we made use of thermal evaporation to deposit Al film in and on the micro array-holes waveguide gate. Note that during process of the thermal evaporation deposition, there is a tiny angle of around degree between evaporation source turret and micro array-holes waveguide gate. The depth of the metal conductive layer in the micro array-holes can be further deepened by the smaller angle, which also enhance the resistivity of the gate films. The characterization of plane surface is showed in the Fig.10. Visibly, there is a metal conductive layer film of around 337nm on the surface of micro array-holes waveguide gate sample. On the other hands, because the thickness of metal conductive layer film on the inner wall of micro array-holes is gradually varied, the thickness and depth of metal conductive layer film on the inner wall is very difficult to exactly measure. But in Fig.10 (a), it is not difficult to find that at least 30% of the inner walls have been covered by the metal conductive layer film, which



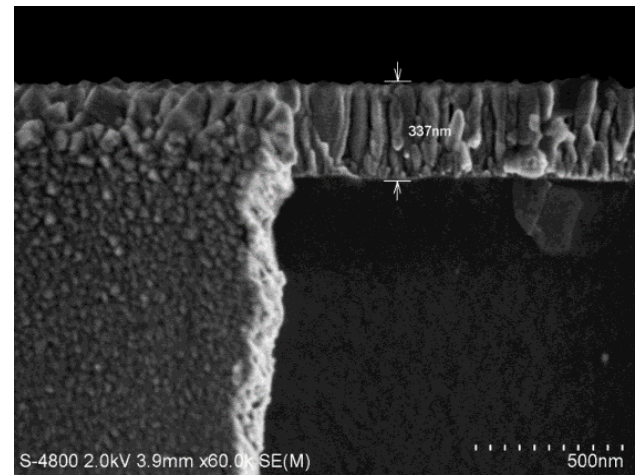
(a) Manufacturing process of induced pits



(a) Manufacturing result of micro array-holes



(a) Macroscopic Characterization Plane Effect



(b) Microscopic Characterization Plane Effect

FIGURE 10. Manufacturing characterization.

FIGURE 9. Substrate manufacturing.

already can estimate the above cutting-edge self-triggered model qualitatively.

Thirdly, in the prototype device, Au film was used as photocathode and it was triggered by an UV LED. The integrated effect of prototype device is shown in Fig.11.

The gap between the MCP₁ and the micro array-holes waveguide gate is restricted by a mica spacer of 30μm. EB allocation and waveguide process simulated by Fig.5 and 6 are verified and tested. In other words, the variation of gate and anode received EB are recorded by changing the electric field distribution between MCP₁ and the micro array-holes waveguide gate. Some tendency of these data basically match with the simulation of Fig.5 and 6. The concrete allocation relationship and testing results are shown in Fig.12. For example, the Fig.5 showed several distribution statuses of electric beam during extreme conditions. The Fig.6 showed a normal divided process of electric beam in the whole waveguide structure. Therefore, whether it is extreme status, or normal divided process, the Fig.12 include all above

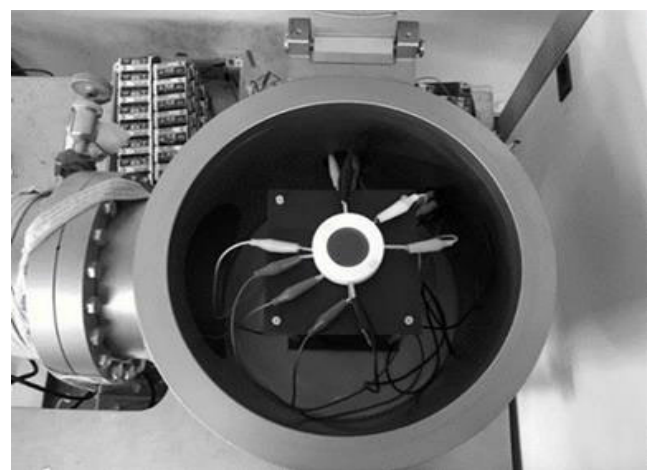


FIGURE 11. Prototype verification system.

status. Namely, the data of Fig.12 reflected that electric beam divided and renewable process, which can verify possibility of achieving self-trigger in terms of device designing.

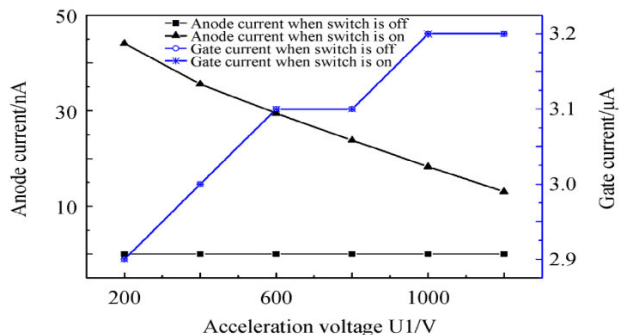


FIGURE 12. Self-trigger allocation relationship.



FIGURE 13. Finally imaging effect on standardized array-holes.

Of course, the concrete designing of self-trigger imaging system is also very important.

Finally, in order to verify that additional self-triggered device structure does affect initial resolution, standardized array-holes are set on the photocathode surface. There is no obviously optical distortion between object and imaging in the Fig.13.

V. CONCLUSION

In this paper, a cutting edge self-trigger detecting mechanism in image intensifier is proposed. This paper firstly researched and analyzed theoretical model and optimized designing method of the new detector. Secondly, in terms of simulation, its waveguide process and work principles were emulated in the CST. Finally, by vacuum test, its self-trigger and space optical transfer ability are verified, and its experiment results basically match with the theoretical analysis and the emulation model. Currently, according to reference of this paper, the time resolution of mainstream range gating imaging systems is only able to achieve several dozen microseconds. Upon our simulation results in the software, the self-trigger device structure can achieve management of electric beam in several dozen picoseconds level. We will integrate the self-trigger device and follow up to report its device characteristics

and system advantages in the next paper. We think that the time resolution of self-trigger device maybe reaches several hundred nanoseconds at least.

To sum up, if this cutting edge invention proposed in this paper would be widely applied in image intensifier, space range-gated imaging system could have a more extensive application and technology upgrading potential in astronomical and military domains.

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